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LABORATORY GROWN DIAMOND REPORT

February 3, 2025

IGI Report Number

LG674535784

Description

LABORATORY GROWN DIAMOND

Shape and Cutting Style

CUT CORNERED RECTANGULAR MODIFIED BRILLIANT

Measurements

8.89 X 6.34 X 4.16 MM

GRADING RESULTS

Carat Weight

2.05 CARATS

Color Grade

F

Clarity Grade

VVS 1

ADDITIONAL GRADING INFORMATION

Polish

EXCELLENT


Symmetry

EXCELLENT

Fluorescence

NONE

Inscription(s)

 LG674535784

Comments: As Grown - No indication of post-growth treatment.
This Laboratory Grown Diamond was created by High Pressure High Temperature (HPHT) growth process.
Type II

PROPORTIONS

Medium (Faceted)


15.5%

46.5%

62%

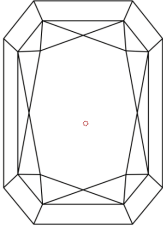
65.6%

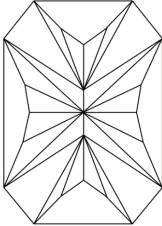
Pointed



Sample Image Used

CLARITY CHARACTERISTICS





KEY TO SYMBOLS

Red symbols indicate internal characteristics.

Green symbols indicate external characteristics.

COLOR

D

E

F

G

H

I

J

Faint

Very Light

Light

CLARITY

IF

VS¹⁻²

VS¹⁻²

SI¹⁻²

I¹⁻³

Internally Flawless

Very Very Slightly Included

Very Slightly Included

Slightly Included

Included

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CUT CORNERED RECT. MODIFIED BRILLIANT

8.89 X 6.34 X 4.16 MM

2.05 CARATS

F

Color Grade

VVS 1

65.6%

62%

Depth

Table

Girdle

Medium (Faceted)

Culet

Polish

Symmetry

Fluorescence


Inscription(s)

Pointed


EXCELLENT

EXCELLENT

NONE



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